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Notice of Allowability	Application No.	Applicant(s)		
	09/688,021	ANNAPRAGADA ET AL.		
	Examiner	Art Unit	1712.	
	Matthew A. Anderson	1765		
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this or other appropriate communical GHTS. This application is subjection	application. If not includ	ed course THIS	
1. X This communication is responsive to amendment of 5/26/2	<u>004</u> .			
2. ☑ The allowed claim(s) is/are <u>1,4-7,10-14,20 and 21</u> .				
3. $igotimes$ The drawings filed on <u>13 October 2000</u> are accepted by the	e Examiner.			
4. Acknowledgment is made of a claim for foreign priority una All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" on oted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give S. CORRECTED DRAWINGS (as "replacement sheets") mus (a) including changes required by the Notice of Draftspers: 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date (dentifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the content of the content	been received. been received in Application No. cuments have been received in the of this communication to file a rep ENT of this application. itted. Note the attached EXAMINE reason(s) why the oath or decla t be submitted. on's Patent Drawing Review (PT Amendment / Comment or in the	ply complying with the recent complying with the recent complying with the recent complying with the recent complying wings in the front (not the	quirements	
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT F 	sit of BIOLOGICAL MATERIAI FOR THE DEPOSIT OF BIOLOG	L must be submitted. I ICAL MATERIAL.	Note the	
Attachment(s)				
I. Notice of References Cited (PTO-892)		Patent Application (PTC	D-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ⊠ Interview Summa Paper No /Mail F	 Interview Summary (PTO-413), Paper No./Mail Date <u>8/10/2004</u>. 		
 Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date 	B), 7. ⊠ Examiner's Amen	7. ⊠ Examiner's Amendment/Comment		
I. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. ⊠ Examiner's Stater 9. □ Other	ment of Reasons for Allo	wance	
		NADINE G. NORTON VISORY PATENT SYA	MINER	

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DETAILED ACTION

Examiner's Amendment

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Michael Lee on 8/10/2004.

Cancel claims 15-18.

Response to Arguments

- 2. Applicant's arguments, see page 6, 3rd paragraph, filed 5/26/2004, with respect to the 35 USC 112 rejection of claims 1,4-7, 10-14 and 20-21 have been fully considered and are persuasive. The rejection of claims 1, 4-7, 10-14 and 20-21 under 35 USC 112 has been withdrawn. The examiner notes the cited support in the specification.
- 3. Applicant's arguments, see page 6+, starting last paragraph, filed 5/26/2004, with respect to 35 USC 103(a) rejection of claims 1, 4-7, 10-13 have

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been fully considered and are persuasive. The rejection of claims 1,4-7, 10-13 under 35 USC 103(a) has been withdrawn. See reasons for allowance below.

4. Applicant's arguments, see top of page 8, filed 5/26/2004, with respect to 35 USC 103(a) rejection of claims 14, 20-21 have been fully considered and are persuasive. The rejection of claims 14, 20-21 under 35 USC 103(a) has been withdrawn. See reasons for allowance below.

Allowable Subject Matter

- 5. Claims 1,4-7, 10-14, 20-21 are allowed.
- 6. The following is an examiner's statement of reasons for allowance:

The use of a flow of etchant gas mixture including C₄F₈, CH₂F₂, oxygen, and CF₄ into a reaction chamber to selectively plasma etch at least one layer of organosilicate glass with respect to an etch stop layer where the organosilicate glass is over the etch stop layer has not been suggested in the prior art. The examiner notes that the previously cited Hung et al. reference does not suggest the above gas constituents were an organo-silicate is etched. Hung et al. suggests adding CH₂F₂ and O₂ to an etchant gas for BPSG (see col. 17 lines 25-25 in reference to Table 10) and not for OSG (organo-silicate glass) etching processes.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should

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preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew A. Anderson whose telephone number is (571) 272-1459. The examiner can normally be reached on M-Th, 7-5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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MAA August 10, 2004

> NADINE G. NORTON SUPERVISORY PATENT EXAMINER